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(54) Title: METHOD OF DECREASING SHEET RESISTANCE IN AN ARTICLE COATED WITH A TRANSPARENT CONDUCTIVE OXIDE

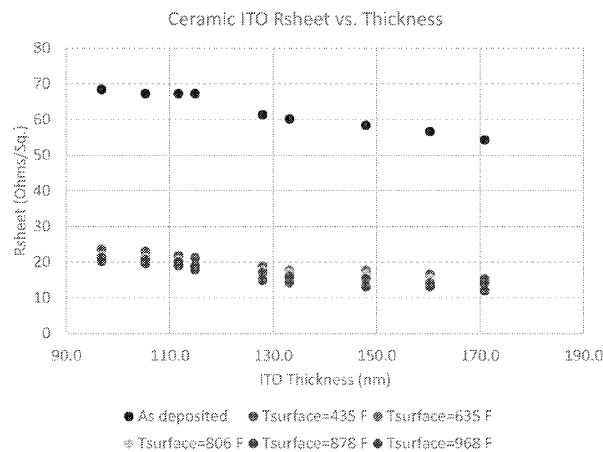


FIG. 7

(57) Abstract: The invention is methods of reducing a sheet resistance or changing emissivity of a coated article. A coating is applied over a substrate wherein that contains a transparent conductive oxide layer at room temperature. The transparent conductive oxide layer is processed by generating an Eddy current in the transparent conductive oxide, flash annealing the transparent conductive oxide layer so that the transparent conductive oxide layer reaches a temperature of above 380°F, or heating the coated article such that the transparent conductive oxide layer is heated to above 380°F.

[Continued on next page]

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